

Fig. 1

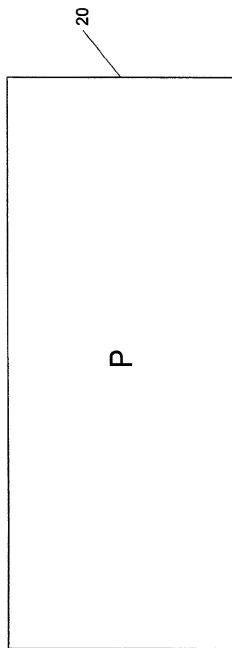


Fig. 2a

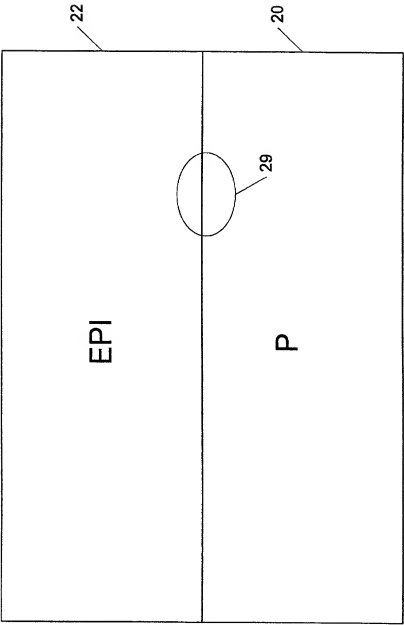


Fig. 2b

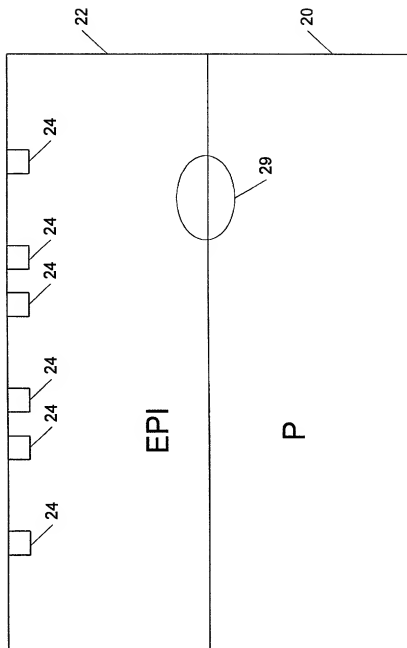


Fig. 2c

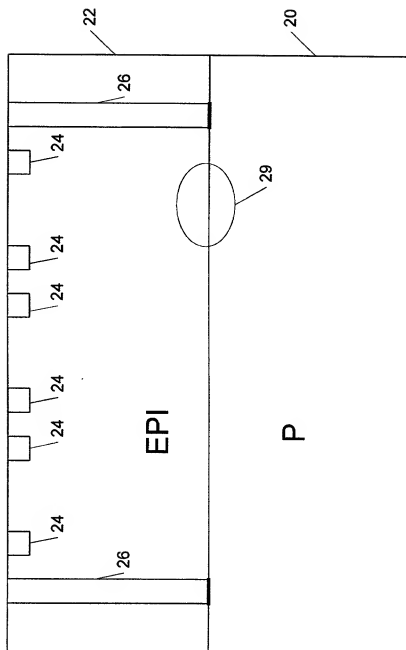


Fig. 2d

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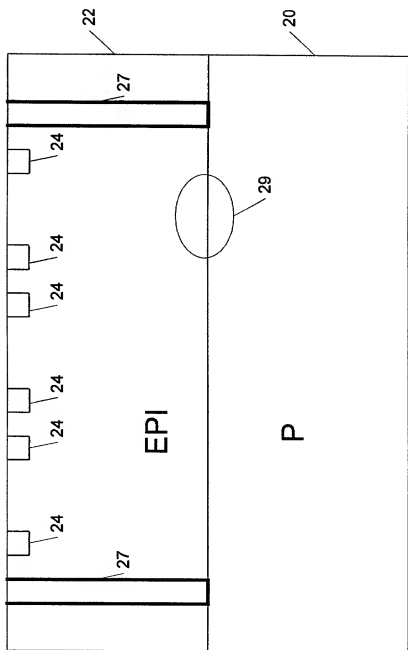


Fig. 2e

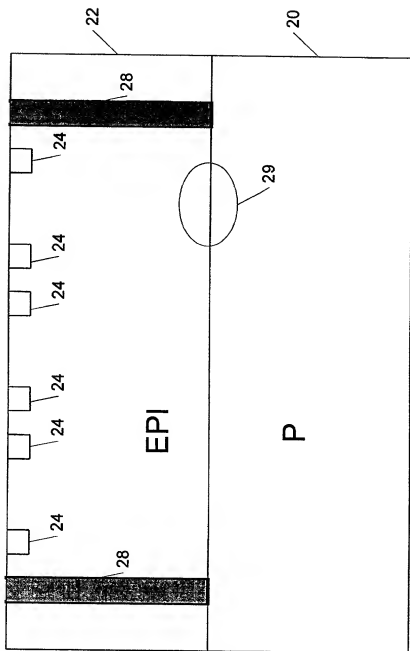


Fig. 2f

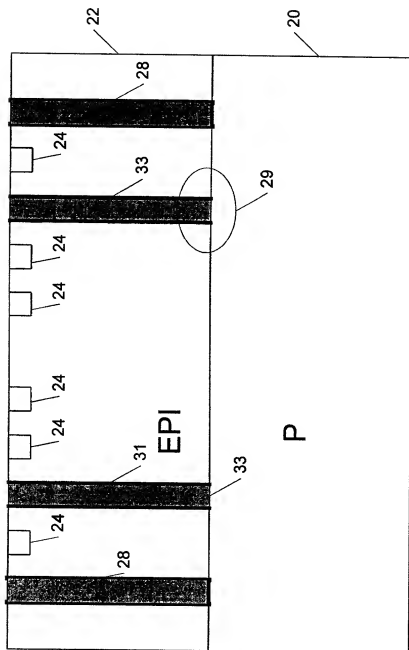


Fig. 2g



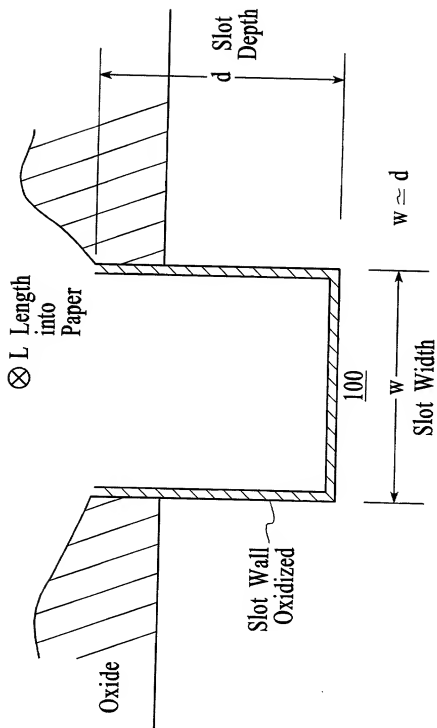


FIG. 3

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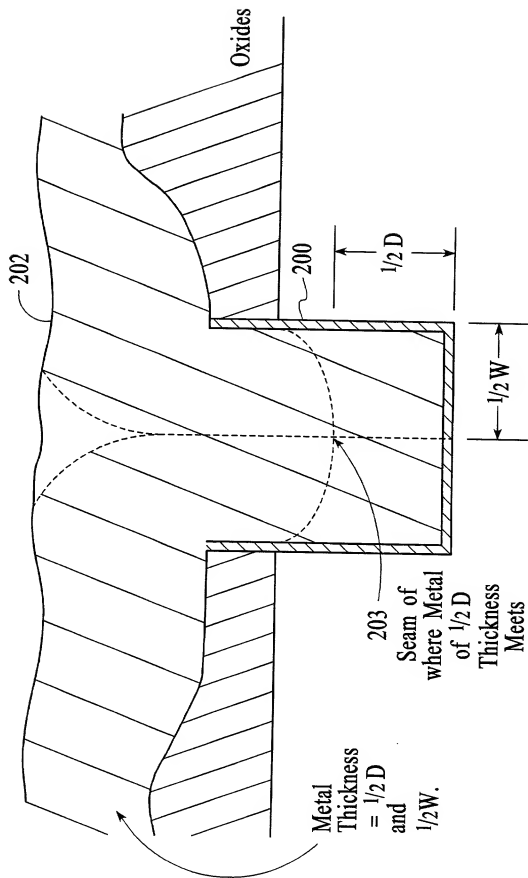
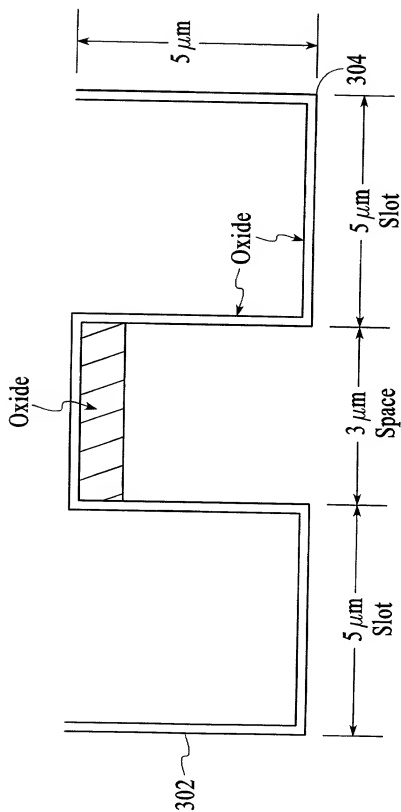


FIG. 4

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Double Slot for  
Double Width of Metal  
 $3\ \mu\text{m}$  Space Between Slots

FIG. 4A

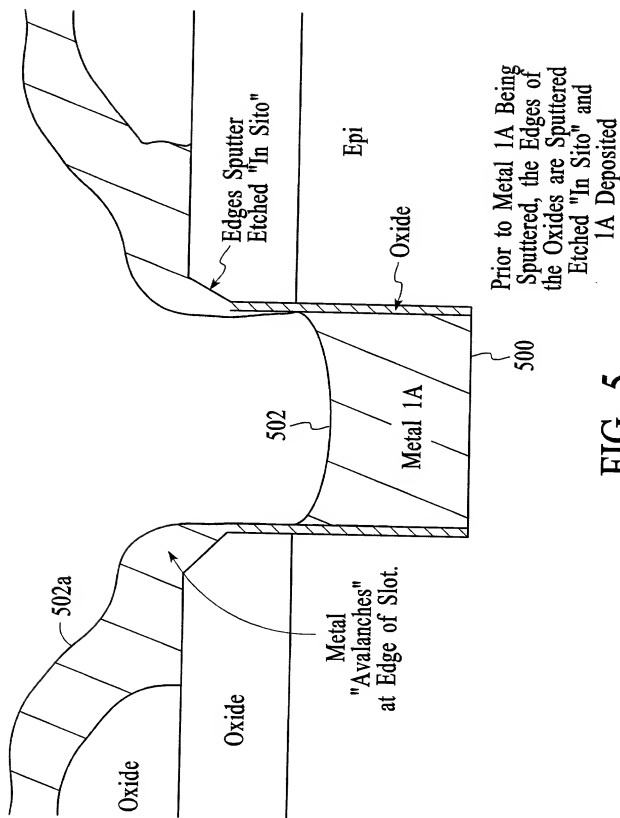


FIG. 5

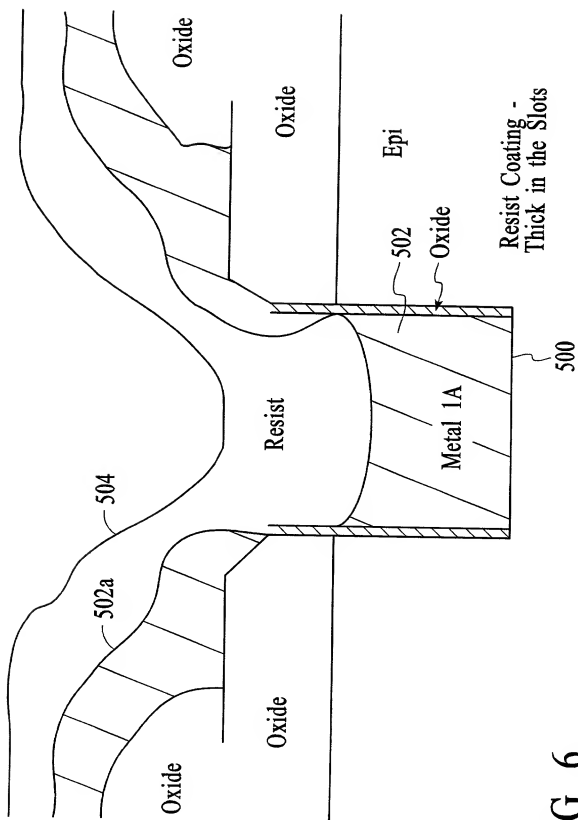
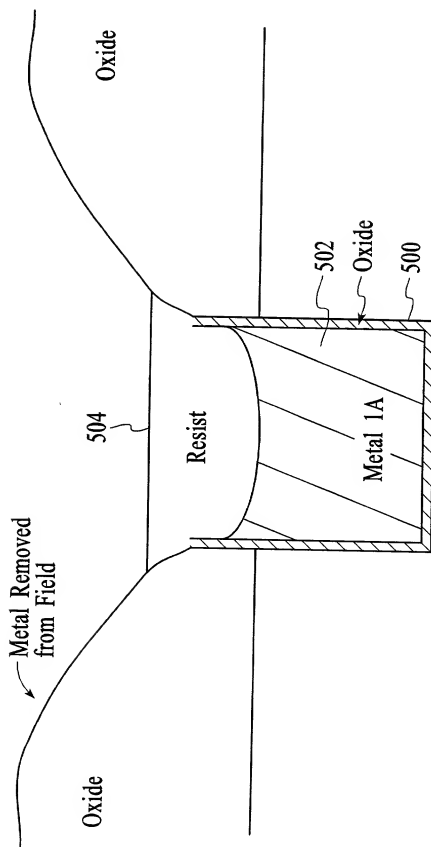
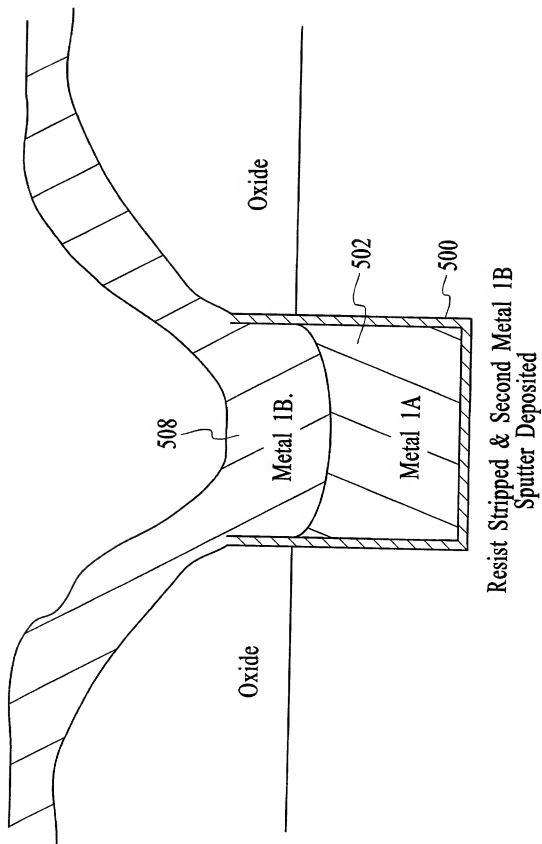


FIG. 6



Resist Planar Etched Leaving Resist  
in Slots. Field Metal Etched Off.

FIG. 7



Resist Stripped & Second Metal 1B  
Sputter Deposited

FIG. 8

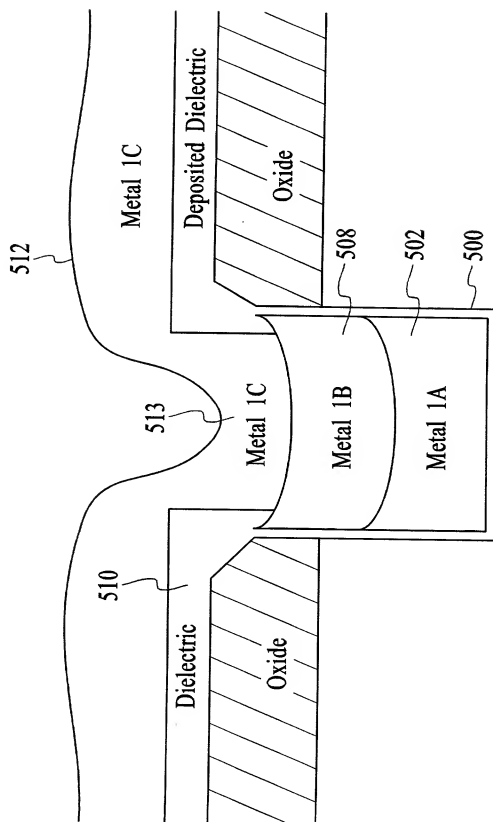


FIG. 9



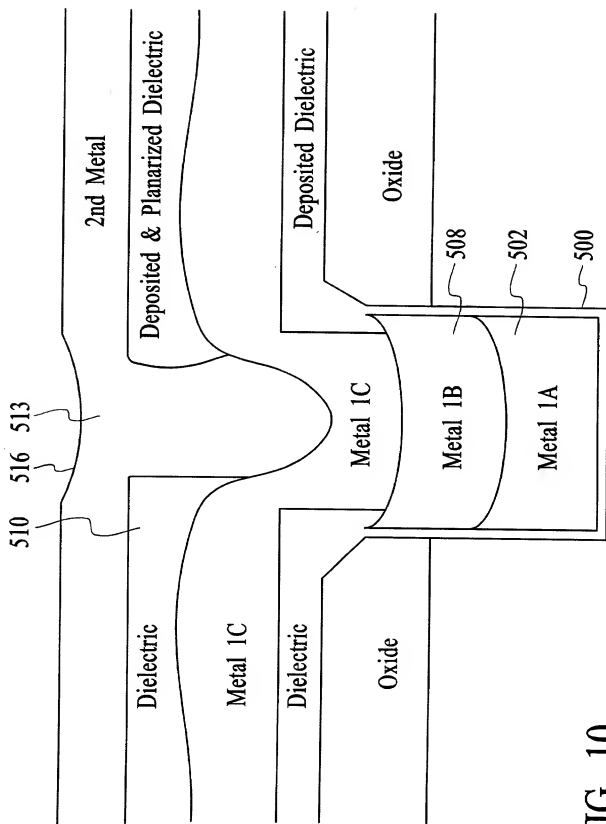


FIG. 10



Shown after layers of Dielectric  
followed by 90 OD Å TEOS -  
Polish - Slot Mask - Metal.  
Metal 1.5 - 2.0  $\mu\text{m}$  deposited.

FIG. 11

## Power Metal

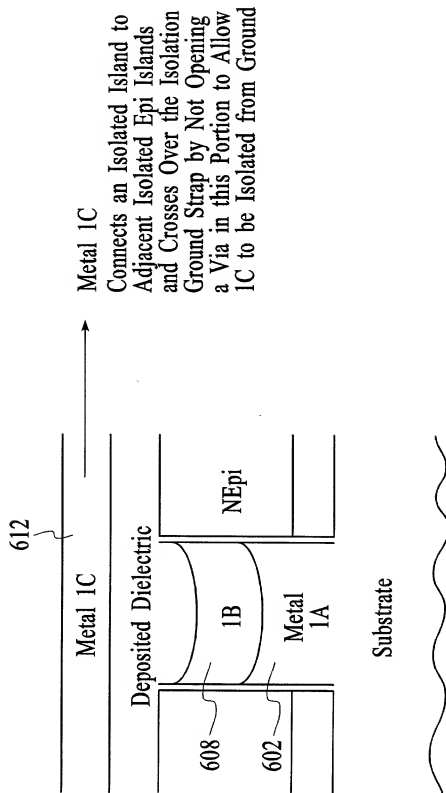


FIG. 12